

CLAIMS

1. High purity copper sulfate wherein the content of Ag impurities is 1wtppm or less, and having a purity of 99.99wt% or higher.
- 5 2. High purity copper sulfate wherein the metalloid element impurities of As, Sb and Bi are respectively 1wtppm or less, and having a purity of 99.99wt% or higher.
3. High purity copper sulfate according to claim 1, wherein the metalloid element impurities of As, Sb and Bi are respectively 1wtppm or less, and  
10 having a purity of 99.99wt% or higher.
4. High purity copper sulfate wherein undissolved residue of  $1\mu\text{m}$  or greater exists in an amount of 100 residues/L or less, and having a purity of 99.99wt% or higher.
5. High purity copper sulfate according to any one of claims 1 to 3,  
15 wherein undissolved residue of  $1\mu\text{m}$  or greater in water exists in an amount of 100 residues/L or less, and having a purity of 99.99wt% or higher.
6. High purity copper sulfate according to any one of claims 1 to 5, having a purity of 99.999wt% or higher.
7. A manufacturing method of high purity copper sulfate including the  
20 steps of dissolving crude copper sulfate crystals or copper metal, and subjecting this to active carbon treatment or solvent extraction and active carbon treatment in order to realize recrystallization.
8. A manufacturing method of high purity copper sulfate according to any one of claims 1 to 6, including the steps of dissolving crude copper sulfate  
25 crystals or copper metal, and subjecting this to active carbon treatment or solvent extraction and active carbon treatment in order to realize recrystallization.